ME 517: Micro- and Nanoscale Processes

Lecture 13: Electrostatics I

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Electrostatics

Coulomb's law—force between two point charges is given by: <u>192</u> 2 0 1 $\epsilon^{\scriptscriptstyle{elect}}$ $^{-}$ $4\pi \varepsilon_{\scriptscriptstyle{0}}^{\vphantom{\dagger}} \varepsilon_{\scriptscriptstyle{r}}^{\vphantom{\dagger}}$ $F_{elect} = \frac{1}{4} \frac{q_1 q_2}{r^2}$ $\pi \varepsilon_0^{\varepsilon} \varepsilon_r^{\varepsilon}$ x =

where q_1 and q_2 are the two charges measured in coulombs (C), x is the distance separating them, ε_0 is the permittivity of free space, ε_r is the relative permittivity of the medium between the charges.

$$
\epsilon_0 {\,=\,} 8.85 x 10^{\text{-}12} \text{ C}^2\text{/N-m}^2
$$

 $\varepsilon_r = 1$ for a vacuum, ≈ 1 for air, > 1 for other materials

Electrostatics

Gauss's law—the electric flux Φ_e through a surface bounding a charge distribution is given by

$$
\Phi_e = \oint_{\Sigma} \vec{E} \cdot d\vec{S} = \frac{1}{\varepsilon_0 \varepsilon_r} \oint_{\Sigma} \vec{D} \cdot d\vec{S}
$$

$$
= \frac{1}{\varepsilon_0 \varepsilon_r} \int_{V} \rho dv = \frac{\text{net charge within } \Sigma}{\varepsilon_0 \varepsilon_r}
$$

where dS is a local surface normal, Σ is the bounding area, E is the electric field, ρ is the charge density, and D is the electric flux density.

It is helpful to construct a potential field such that

$$
\vec{E}\left(\text{space}\right) = -\nabla W\left(\text{space}\right)
$$

where W is the electrostatic potential measured in J/C (or volts)

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Electrostatics

Define the potential energy W_e stored in an electrostatic field as:

$$
W_e = \frac{1}{2} \int_V \rho V dv = \frac{1}{2} \int_V \varepsilon_0 \varepsilon_r \left| \vec{E} \right|^2 dv
$$

where W_e is measured in Joules.

Physically W_e represents the total amount of work that would be required to place the charge within the electrostatic field.

We call the above geometry a capacitor and define its capacitance as

$$
C = \frac{Q}{\Delta V}
$$

where C is measured in C/V, a unit defined as the farad (F).

Source: wikipedia

Typical Capacitors

Capacitor

- Simplest geometry—parallel plate above
- Assuming that *d* is much smaller than *v* or *w*, fringing will not play a major role assume that the field is uniform.

$$
W_e = \frac{1}{2} \int_V \rho V dv = \frac{1}{2} \int_V \varepsilon_0 \varepsilon_r \left(\frac{V}{d}\right)^2 dv
$$

$$
= \frac{1}{2} \varepsilon_0 \varepsilon_r \left(\frac{V}{d}\right)^2 vwd = \frac{1}{2} \varepsilon_0 \varepsilon_r \frac{vw}{d} V^2
$$

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Calculate force exerted on free plate by fixed plate

Force is the gradient of potential so

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